

OPI INFORMATION DISCLOSURE CITATION IN AN APPLICATION				Document Number (Specified) TSMC-02-029	Application Number 10/772,939	
				Applicant Liang - Gi Yao et al.		
				Filing Date 02/05/04	Group Art Unit 10	
U. S. PATENT DOCUMENTS						
TYPE SEARCHED	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	REASON DATE IF APPROPRIATE
PD	6388307	5/14/02	Kondo et al.	257	592	8/18/99
	5976941	11/2/99	Boles et al.	438	349	6/6/97
✓	5273930	12/28/93	Steele et al.	437	89	9/3/92
PD	5620907	4/15/97	Jalali-Farahani et al.	438	320	3/4/96
FOREIGN PATENT DOCUMENTS						
	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATED YES NO
OTHER DOCUMENTS (including Author, Title, Date, Page No., Etc.)						
EXAMINER				DATE CONSIDERED		
PHUC T. DANG				3/22/2005		
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